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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Attorney Docket No. 016778/0437

Applicant: Yukio MORISHIGE et al.
Title: METHOD AND DEVICE FOR CORRECTING PATTERN
FILM ON A SEMICONDUCTOR SUBSTRATE
Application No.: 09/981,712
Filing Date: October 19, 2001
Examiner: Hassanzadeh, Parviz
Art Unit: 1763

AMENDMENT AND REPLY UNDER 37 C.F.R. 1.116

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This communication is responsive to the Final Office Action dated May 17, 2004, concerning the above-referenced patent application.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this document.

Remarks/Arguments begin on page 7 of this document.

Please amend the application as follows: